an insulating film covering the first and second gate lines and the first and the second data lines;

a pixel electrode disposed in the pixel region, the pixel electrode overlapping one of the first and the second regions of the first data line, the pixel electrode overlapping one of the first and second regions of the second data line such that one of the first and second regions of the first data line and one of the first and second regions of the second data line are not overlapped by the pixel electrode; and

a switching element disposed in the pixel region and connected between the second gate line and the pixel electrode.

12 — 12. (Amended) A method of manufacturing a liquid crystal display device, comprising the steps of:

providing a substrate;

forming first and second gate lines formed on the substrate;

forming first and second data lines intersecting the first and second gate lines so as to define a pixel region, wherein each one of the first and second data lines has longitudinally separated first and second regions;

forming an insulating film covering the first and second gate lines and the first and the second data lines;

forming a switching element disposed in the pixel region and connected between the second gate line and the pixel electrode; and

forming a pixel electrode in the pixel region to overlap one of the first and the second regions of the first data line, and to overlap one of the first and second regions

of the second data line such that one of the first and second regions of the first data line and one of the first and second regions of the second data line are not overlapped by the pixel electrode.

18. (Amended) The method of claim 13, wherein the pixel electrode extends over the first region of the first date line and extends over the second region of the second data line.